Matter No.: 07977-024004 Applicant(s): Isamu Kobori et al.

METHOD OF MANUFACTURING A SEMICONDUCTOR METHOD OF MANUFACTURING A THIN-FILM TRANSISTOR

AND THIN-FILM TRANSISTOR

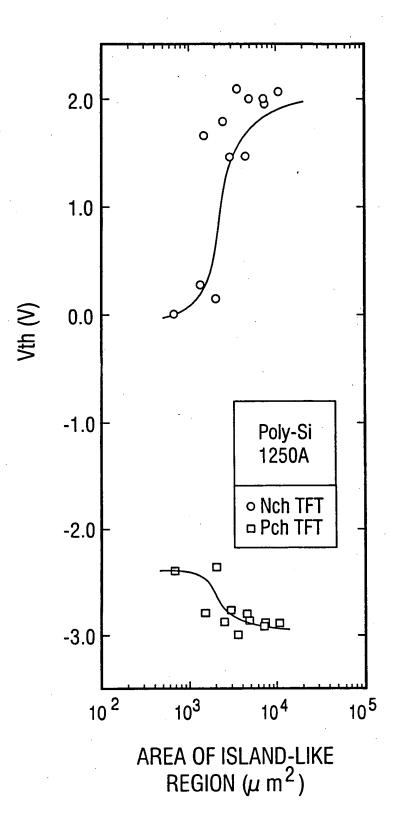


Figure 1

METHOD OF MANUFACTURING A SEMICONDUCTOR METHOD OF MANUFACTURING A THIN-FILM TRANSISTOR AND THIN-FILM TRANSISTOR

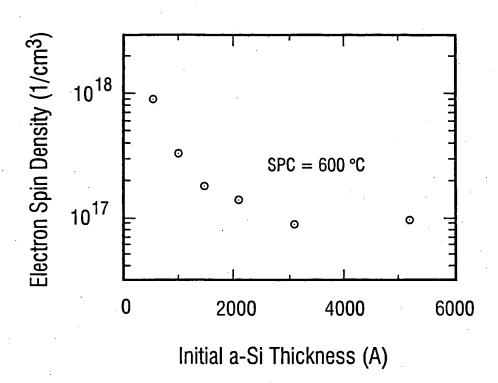


Figure 2

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AND THIN-FILM TRANSISTOR

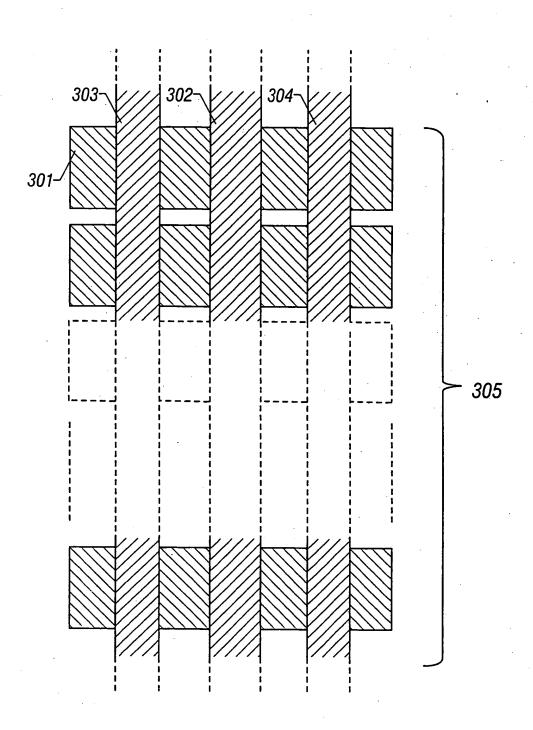


Figure 3

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AND THIN-FILM TRANSISTOR

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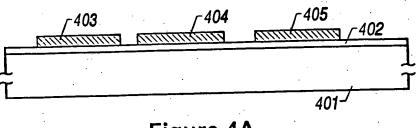


Figure 4A

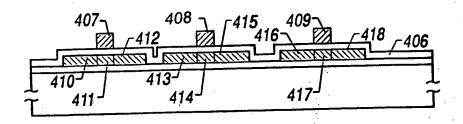


Figure 4B

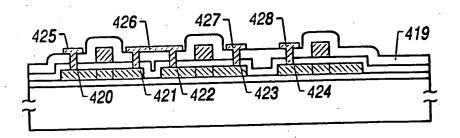


Figure 4C

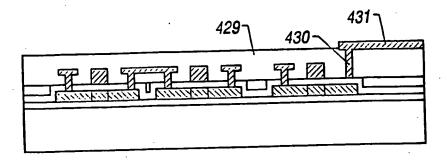


Figure 4D

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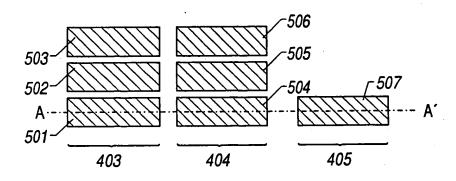


Figure 5A

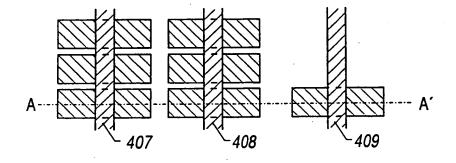


Figure 5B

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METHOD OF MANUFACTURING A SEMICONDUCTOR METHOD OF MANUFACTURING A THIN-FILM TRANSISTOR

AND THIN-FILM TRANSISTOR

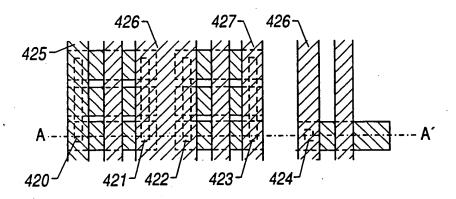


Figure 5C

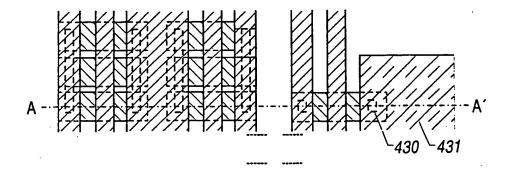


Figure 5D